

S&S TECH (주)에스앤에스텍

Investors Relations

Y2025



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Global Leader in Mask Blank & EUV Nano- technology



Company Name	S&S Tech Corporation
CEO & Chairman	Jeong, SooHong
Founded	February 22 nd , 2001
Employees	305 (As of 2025. 01)
Business	Mask Blank for Semiconductor and FPD
Public Listing	KOSDAQ (101490)
Headquarter	Daegu, South Korea
Patents	225 listed (Domestic 104/ International 121)



EUV Center

- Location : Yongin City
- Establish : '24/3Q
- Land : 8,250 [m²]
- C/R : 3,630 [m²]
- Product : [EUV product](#)



Daegu Headquarter

- Location : Daegu City
- Land : 13,200 [m²]
- C/R : 5,450 [m²]
- Product : Optical Mask Blank & [EUV product](#)

2001 ~ 2009

1. Market Entry

- Established S&S Tech
- Korea's first development and production of IC/FPD Mask Blank
- 2005 Newtech Award from the President of Korea
- 2008 Appointed as Korea's Top 10 New Tech
- USD \$20M Export

2009 ~ 2016

2. Growth Period

- High-End Market Entry
- 2009 KOSDAQ IPO
- 2014 World Class 300
- 2016 2nd Production Site Expansion in Daegu

2017 ~ 2024

3. Expansion Period

- 2017 EUV Pellicle Development
- 'High-Tech Company' Certification
- 2020 EUV Mask Blank Development
- 2024 EUV Center in Yongin Established

2025 ~

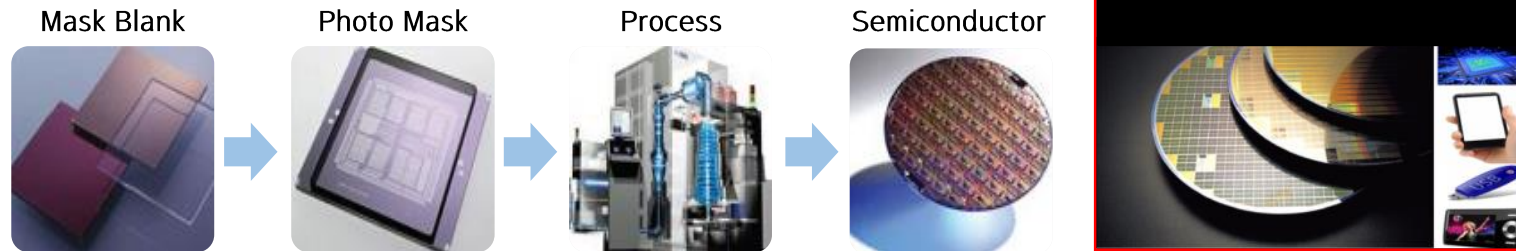
4. Upcoming Items

- EUV Pellicle Business
- EUV Mask Blank full development & Business

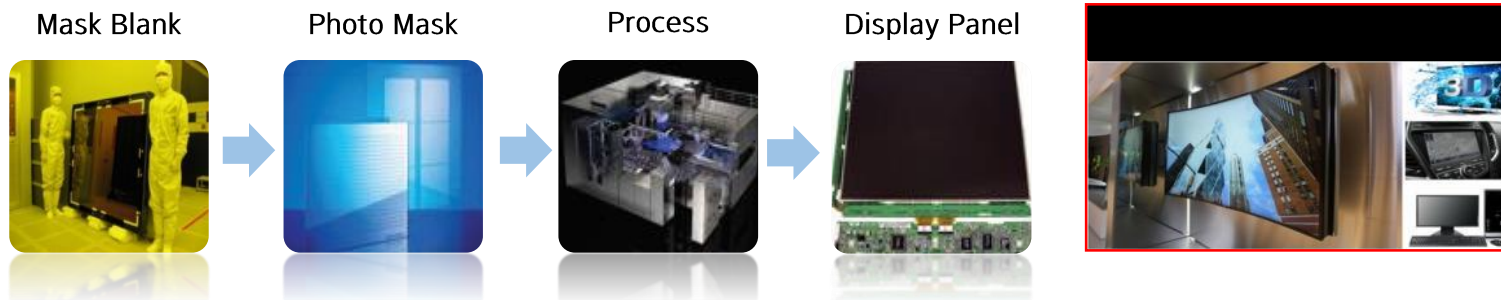
First Locally Developed – Mask Blank

- Mask Blank is the main raw material for photomasks/reticle (without patterns) and can be applied to semiconductors (Memory and Non-memory) and display (TFT-LCD, OLED, LED)

Semiconductor Mask Blank



Display Mask Blank



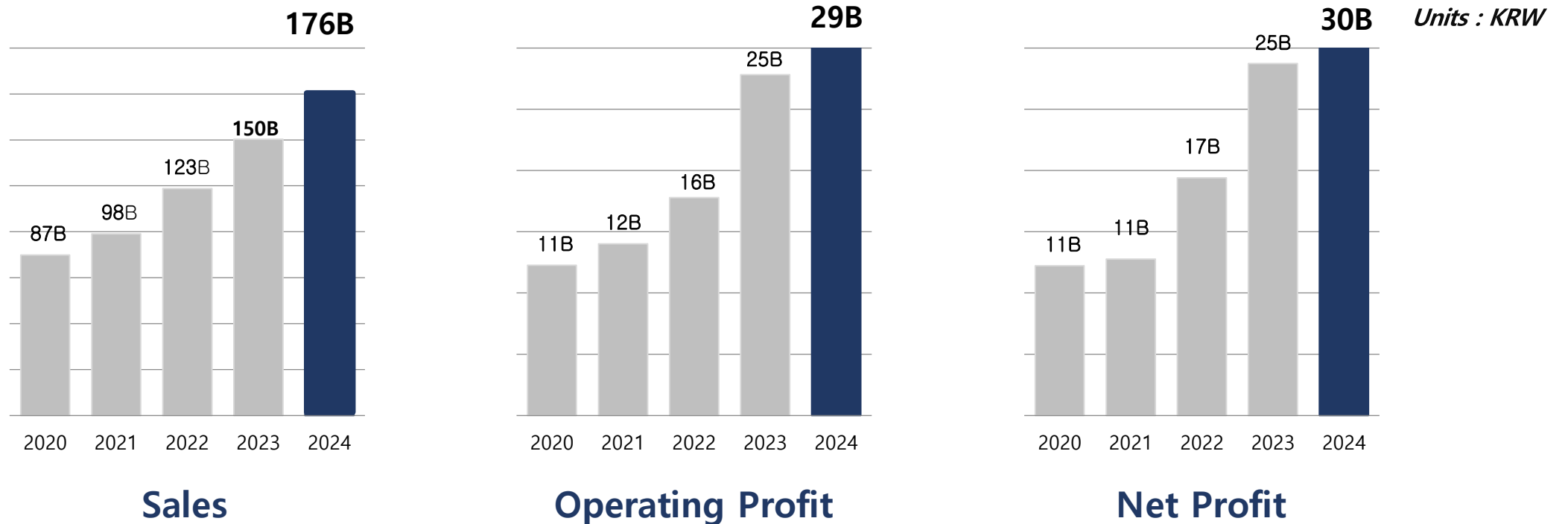
Key Figures



Financial	+19% YoY	+27% YoY	176B	29B
	Revenue 5Y CAGR 2020~2024 (Consolidated)	Operating Profit 5Y CAGR 2020~2024 (Consolidated)	Revenue Y2024 Consolidated	Operating Profit Y2024 Consolidated
Ownership	225	305	Investment, Bio Lab	<i>Units : KRW</i>
	Patents Listed Domestic & International	Employees As of 2025. 01	S&S Investment S&S Lab	
Customers	About 66%	About 30+		
	Export rate by total revenue	# of Customers Globally		

2024 Financial Summary (Consolidated YoY)

- In 2024, sales reached 176B KRW with an operating profit of 29.5B KRW, maintaining an annual growth rate of around 19% over the past 5 years.
- With the growth of the next- generation semiconductor and display markets, annual revenue continues to rise.



Key Investment Points

01. Steady Growth in Sales

- ✓ Maintaining a CAGR of +19% in sales and +27% in OP over the past 5 years.

03. Growth in Semiconductor & FPD market

- ✓ Securing market share and customers in the growing semiconductor and display sectors

02. Future Oriented Business Structure

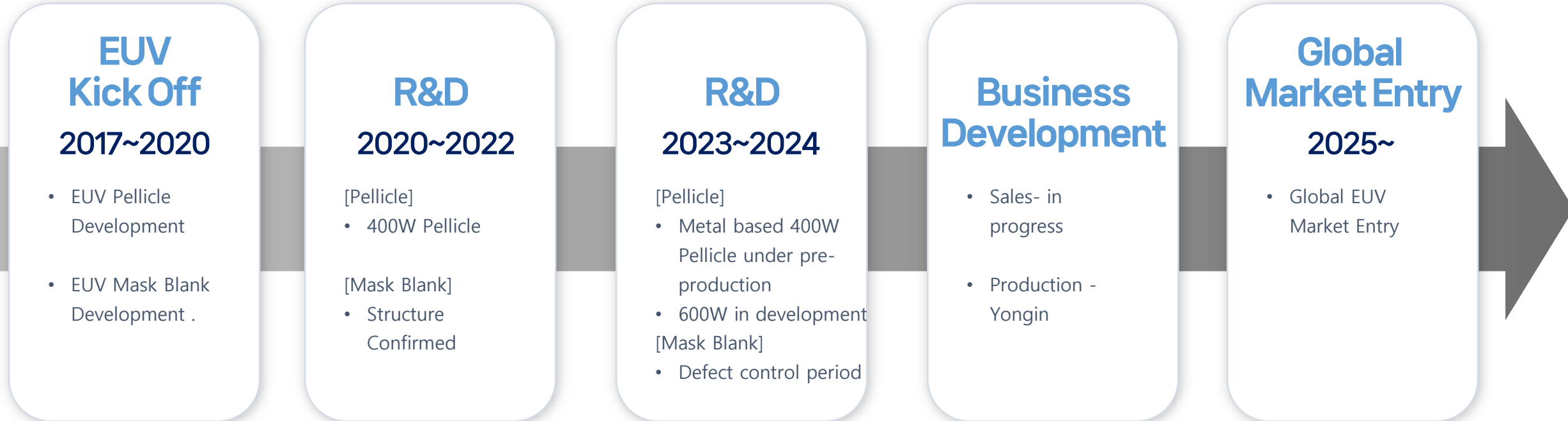
- ✓ Investment in facilities and equipment tools for the next generation semiconductor
- ✓ Established an EUV Center in Yongjin for HVM

04. Partnership with customers based on credibility

- ✓ Leveraging existing connections and networking expertise to target a broader and diverse customer base

EUV R&D Roadmap

- S&S Tech has been investing in EUV Products since 2017, establishing a commercialization structure through a top-tier R&D system.



Thank you.

EOD